

List of reviewers

August 5, 2005 to May 16, 2006

We acknowledge contributions as reviewers to Computers & Graphics from the following international experts

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Reviewers have been considered in this list who have returned their comments in the time between August 5, 2005 and May 16, 2006!

This list does not include reviewers for papers from Special Issues and for the sections “Chaos & Graphics” and “Education”!